MIL-PRF-19500/752 2 June 2010

### PERFORMANCE SPECIFICATION SHEET

SEMICONDUCTOR DEVICE, FIELD EFFECT TRANSISTOR, N-CHANNEL, RADIATION HARDENED (TOTAL DOSE AND SINGLE EVENT EFFECTS), LOGIC-LEVEL SILICON, TYPE 2N7608T2, JANTXVR, JANTXVF, JANSR, AND JANSF

This specification is approved for use by all Departments and Agencies of the Department of Defense.

The requirements for acquiring the product described herein shall consist of this specification sheet and MIL-PRF-19500.

#### 1. SCOPE

- 1.1 <u>Scope</u>. This specification covers the performance requirements for a N-channel, enhancement-mode, radiation hardened (total dose and single event effects (SEE)), low-threshold logic level, MOSFET, transistor. Two levels of product assurance are provided for each device type as specified in MIL-PRF-19500, with avalanche energy maximum rating (E<sub>AS</sub>) and maximum avalanche current (I<sub>AS</sub>).
  - 1.2 Physical dimensions. See figure 1, TO-39 (TO-205AF).
  - 1.3 Maximum ratings. Unless otherwise specified,  $T_A = +25$ °C.

Туре	P <sub>T</sub> (1) T <sub>C</sub> =+25°C	P <sub>T</sub> T <sub>A</sub> =+25°C	R <sub>θJC</sub> (2)	$V_{ extsf{DS}}$	$V_{GS}$	I <sub>D1</sub> T <sub>C</sub> =+25°C (3) (4)	I <sub>D2</sub> T <sub>C</sub> =+100°C (3) (4)	Is	I <sub>DM</sub> (5)	$T_{J}$ and $T_{STG}$
	W	<u>W</u>	<u>°C/W</u>	V dc	V dc	A dc	A dc	A dc	<u>A (pk)</u>	<u>°С</u>
2N7608T2	23	0.63	5.5	100	±10	6.0	3.7	6.0	24	-55 to +150

- (1) Derate linearly by 0.18 W/ $^{\circ}$ C for T<sub>C</sub> > +25 $^{\circ}$ C.
- (2) See figure 2, thermal impedance curves.
- (3) The following formula derives the maximum theoretical I<sub>D</sub> limit. I<sub>D</sub> is limited to 12 A by package and internal construction.

$$I_{\rm D} = \sqrt{\frac{T_{\rm JM} - T_{\rm C}}{\left(R_{\rm \theta JC}\right) x \left(R_{\rm DS}(\text{ on }) \text{ at } T_{\rm JM}\right)}}$$

- (4) See figure 3, maximum drain current graph.
- (5)  $I_{DM} = 4 \times I_{D1}$  as calculated in note (3).

Comments, suggestions, or questions on this document should be addressed to Defense Supply Center, Columbus, ATTN: DSCC-VAC, P.O. Box 3990, Columbus, OH 43218-3990, or emailed to <a href="mailto:Semiconductor@dscc.dla.mil">Semiconductor@dscc.dla.mil</a>. Since contact information can change, you may want to verify the currency of this address information using the ASSIST Online database at <a href="https://assist.daps.dla.mil">https://assist.daps.dla.mil</a>.

AMSC N/A FSC 5961

1.4 Maximum ratings. Unless otherwise specified,  $T_C = +25$ °C.

Туре	Min V(BR) DSS	VGS (th)1	Max $PS(0)$ IDSS1  VGS = 4.5				
	$V_{GS} = 0 V$ $I_D = 250 \mu A dc$	$V_{DS} = V_{GS}$ $I_{D} = 250 \mu A dc$	V <sub>GS</sub> = 0 V V <sub>DS</sub> = 80% rated V <sub>DS</sub>	T <sub>J</sub> = +25°C at I <sub>D2</sub>	T <sub>J</sub> = +150°C at I <sub>D2</sub>		
	V dc	<u>V dc</u> <u>Min Max</u>	μA dc	<u>Ohm</u>	<u>Ohm</u>	mJ	A dc
2N7608T2	100	1.0 2.0	1.0	0.30	0.65	43	6

(1) Pulsed (see 4.5.1).

#### 2. APPLICABLE DOCUMENTS

2.1 <u>General</u>. The documents listed in this section are specified in sections 3, 4, or 5 of this specification. This section does not include documents cited in other sections of this specification or recommended for additional information or as examples. While every effort has been made to ensure the completeness of this list, document users are cautioned that they must meet all specified requirements of documents cited in sections 3, 4, or 5 of this specification, whether or not they are listed.

#### 2.2 Government documents.

2.2.1 <u>Specifications, standards, and handbooks</u>. The following specifications, standards, and handbooks form a part of this document to the extent specified herein. Unless otherwise specified, the issues of these documents are those cited in the solicitation or contract.

#### DEPARTMENT OF DEFENSE SPECIFICATIONS

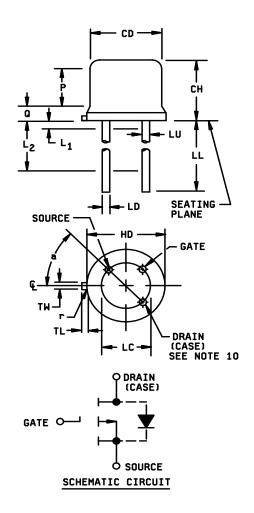
MIL-PRF-19500 - Semiconductor Devices, General Specification for.

## DEPARTMENT OF DEFENSE STANDARDS

MIL-STD-750 - Test Methods for Semiconductor Devices.

(Copies of these documents are available online at <a href="https://assist.daps.dla.mil/quicksearch/">https://assist.daps.dla.mil/quicksearch/</a> or <a href="https://assist.daps.dla.mil/">https://assist.daps.dla.mil/</a> or from the Standardization Document Order Desk, 700 Robbins Avenue, Building 4D, Philadelphia, PA 19111-5094.)

2.3 <u>Order of precedence</u>. Unless otherwise noted herein or in the contract, in the event of a conflict between the text of this document and the references cited herein, the text of this document takes precedence. Nothing in this document, however, supersedes applicable laws and regulations unless a specific exemption has been obtained.



	Dimensions							
Ltr	Inch	nes	Millir	Millimeters				
	Min	Max	Min	Max				
CD	.305	.335	7.75	8.51				
CH	.160	.180	4.06	4.57				
HD	.335	.370	8.51	9.39				
LC	.200	TP	5.0	8 TP	6			
LD	.016	.021	0.41	0.53	7, 8			
LL	.500	.750	12.7	19.05	7, 8			
LU	.016	.019	0.41	0.48	7, 8			
L <sub>1</sub>		.050		1.27	7, 8			
L <sub>2</sub>	.250		6.35		7, 8			
Р	.100		2.54		5			
Q		.050		1.27	4			
r		.010		0.25	9			
TL	.029	.045	0.74	1.14	3			
TW	.028	.034	0.71	0.86	2			
α	45°	TP	45	° TP	6			

# NOTES:

- 1. Dimensions are in inches. Millimeters are given for general information only.
- 2. Beyond radius (r) maximum, TW shall be held for a minimum length of .011 inch (0.28 mm).
- 3. Dimension TL measured from maximum HD.
- 4. Outline in this zone is not controlled.
- 5. Dimension CD shall not vary more than .010 inch (0.25 mm) in zone P. This zone is controlled for automatic handling.
- 6. Leads at gauge plane .054 +.001, -.000 inch (1.37 +0.03, -0.00 mm) below seating plane shall be within .007 inch (0.18 mm) radius of true position (TP) at maximum material condition (MMC) relative to tab at MMC.
- 7. LU applies between L<sub>1</sub> and L<sub>2</sub>. LD applies between L<sub>2</sub> and LL minimum. Diameter is uncontrolled in L<sub>1</sub> and beyond LL minimum.
- 8. All three leads.
- 9. Radius (r) applies to both inside corners of tab.
- 10. Drain is electrically connected to the case.
- 11. In accordance with ASME Y14.5M, diameters are equivalent to φx symbology.

FIGURE 1. Physical dimensions for TO-205AF (2N7608T2).

#### 3. REQUIREMENTS

- 3.1 General. The individual item requirements shall be as specified in MIL-PRF-19500 and as modified herein.
- 3.2 <u>Qualification</u>. Devices furnished under this specification shall be products that are manufactured by a manufacturer authorized by the qualifying activity for listing on the applicable qualified manufacturer's list before contract award (see 4.2 and 6.3).
- 3.3 <u>Abbreviations, symbols, and definitions</u>. Abbreviations, symbols, and definitions used herein shall be as specified in MIL-PRF-19500.
- 3.4 <u>Interface and physical dimensions</u>. Interface and physical dimensions shall be as specified in MIL-PRF-19500 and figure 1 herein.
- 3.4.1 <u>Lead finish</u>. Lead finish shall be solderable in accordance with MIL-PRF-19500, MIL-STD-750, and herein. Where a choice of lead finish is desired, it shall be specified in the acquisition document (see 6.2).
  - 3.4.2 Internal construction. Multiple chip construction shall not be permitted.
  - 3.5 Marking. Marking shall be in accordance with MIL-PRF-19500.
  - 3.6 Electrostatic discharge protection. The devices covered by this specification require electrostatic protection.
- 3.6.1 <u>Handling</u>. MOS devices must be handled with certain precautions to avoid damage due to the accumulation of static charge. The following handling practices shall be followed:
  - a. Devices shall be handled on benches with conductive handling devices.
  - b. Ground test equipment, tools, and personnel handling devices.
  - c. Do not handle devices by the leads.
  - d. Store devices in conductive foam or carriers.
  - e. Avoid use of plastic, rubber, or silk in MOS areas.
  - f. Maintain relative humidity above 50 percent if practical.
  - g. Care shall be exercised, during test and troubleshooting, to apply not more than maximum rated voltage to any lead.
  - h. Gate must be terminated to source,  $R \le 100 \text{ k}\Omega$ , whenever bias voltage is to be applied drain to source.
- 3.7 <u>Electrical performance characteristics</u>. Unless otherwise specified herein, the electrical performance characteristics are as specified in 1.3, 1.4, and table I.
  - 3.8 <u>Electrical test requirements</u>. The electrical test requirements shall be the subgroups specified in table I herein.
- 3.9 <u>Workmanship</u>. Semiconductor devices shall be processed in such a manner as to be uniform in quality and shall be free from other defects that will affect life, serviceability, or appearance.

#### 4. VERIFICATION

- 4.1 <u>Classification of Inspections</u>. The inspection requirements specified herein are classified as follows:
  - a. Qualification inspection (see 4.2).
  - b. Screening (see 4.3).
  - c. Conformance inspection (see 4.4 and table I and II).
- 4.2 Qualification inspection. Qualification inspection shall be in accordance with MIL-PRF-19500 and as specified herein.
- 4.2.1 <u>Group E qualification</u>. Group E inspection shall be performed for qualification or re-qualification only. In case qualification was awarded to a prior revision of the specification sheet that did not request the performance of table III tests, the tests specified in table III herein that were not performed in the prior revision shall be performed on the first inspection lot of this revision to maintain qualification.
- 4.2.1.1 <u>SEE</u>. Design capability shall be tested on the initial qualification and thereafter whenever a major die design or process change is introduced (see table III). End-point measurements shall be in accordance with table II.

4.3 <u>Screening (JANS, JANTX, and JANTXV levels only)</u>. Screening shall be in accordance with table E-IV of MIL-PRF-19500 and as specified herein. The following measurements shall be made in accordance with table I herein. Devices that exceed the limits of table I herein shall not be acceptable.

Screen (see table E-IV	Measurement						
of MIL-PRF-19500) (1) (2)	JANS	JANTXV					
(3)	Gate stress test (see 4.3.1)	Gate stress test (see 4.3.1)					
(3)	Method 3470 of MIL-STD-750, E <sub>AS</sub> (see 4.3.2)	Method 3470 of MIL-STD-750, E <sub>AS</sub> (see 4.3.2)					
(3) 3c	Method 3161 of MIL-STD-750, thermal impedance, (see 4.3.3)	Method 3161 of MIL-STD-750, thermal impedance, (see 4.3.3)					
9	Subgroup 2 of table I herein IDSS1, IGSSF1, IGSSR1 as minimum	Not applicable					
10	Method 1042 of MIL-STD-750, test condition B	Method 1042 of MIL-STD-750, test condition B					
11	$\begin{split} &I_{GSSF1},I_{GSSR1},I_{DSS1},r_{DS(ON)1},V_{GS(TH)1}\\ &Subgroup\ 2\ of\ table\ I\ herein \end{split}$ $&\Delta I_{GSSF1}=\pm 20\ nA\ dc\ or\ \pm 100\ percent\ of\ initial\ value,\ whichever\ is\ greater.\\ &\Delta I_{GSSR1}=\pm 20\ nA\ dc\ or\ \pm 100\ percent\ of\ initial\ value,\ whichever\ is\ greater.\\ &\Delta I_{DSS1}=\pm 1\ \mu A\ dc\ or\ \pm 100\ percent\ of\ initial\ value,\ whichever\ is\ greater. \end{split}$	I <sub>GSSF1</sub> , I <sub>GSSR1</sub> , I <sub>DSS1</sub> , r <sub>DS(ON)1</sub> , V <sub>GS(TH)1</sub> Subgroup 2 of table I herein					
12	Method 1042 of MIL-STD-750, test condition A	Method 1042 of MIL-STD-750, test condition A					
13	Subgroups 2 and 3 of table I herein $\Delta I_{GSSF1} = \pm 20$ nA dc or $\pm 100$ percent of initial value, whichever is greater. $\Delta I_{GSSR1} = \pm 20$ nA dc or $\pm 100$ percent of initial value, whichever is greater. $\Delta I_{DSS1} = \pm 1$ $\mu A$ dc or $\pm 100$ percent of initial value, whichever is greater. $\Delta I_{DS(ON)1} = \pm 20$ percent of initial value. $\Delta V_{GS(TH)1} = \pm 20$ percent of initial value.	Subgroup 2 of table I herein $\Delta I_{GSSF1} = \pm 20$ nA dc or $\pm 100$ percent of initial value, whichever is greater. $\Delta I_{GSSR1} = \pm 20$ nA dc or $\pm 100$ percent of initial value, whichever is greater. $\Delta I_{DSS1} = \pm 1$ $\mu A$ dc or $\pm 100$ percent of initial value, whichever is greater. $\Delta I_{DSS(N)1} = \pm 20$ percent of initial value. $\Delta V_{GS(TH)1} = \pm 20$ percent of initial value.					

- (1) At the end of the test program,  $I_{GSSF1}$ ,  $I_{GSSR1}$ , and  $I_{DSS1}$  are measured.
- (2) An out-of-family program to characterize I<sub>GSSF1</sub>, I<sub>GSSR1</sub>, I<sub>DSS1</sub>, and V<sub>GS(th)1</sub> shall be invoked.
- (3) Shall be performed anytime after temperature cycling, screen 3a; and does not need to be repeated in screening requirements.

- 4.3.1 Gate stress test. Apply VGS = 15 V minimum for t = 250  $\mu$ s minimum.
- 4.3.2 Single pulse avalanche energy (E<sub>AS</sub>).
  - a. Peak current (I<sub>AS</sub>).....I<sub>D1</sub>.
  - b. Peak gate voltage (V<sub>GS</sub>)......10 V dc, up to rated V<sub>GS</sub>.
  - c. Gate to source resistor (R<sub>GS</sub>)......25  $\leq$  R<sub>GS</sub>  $\leq$  200  $\Omega$ .
  - d. Initial case temperature ......+25°C, +10°C, -5°C.

  - f. Number of pulses to be applied ......1 pulse minimum.
  - g. Supply voltage (V<sub>DD</sub>)......25 V dc.
- 4.3.3 <u>Thermal impedance</u>. The thermal impedance measurements shall be performed in accordance with method 3161 of MIL-STD-750 using the guidelines in that method for determining  $I_M$ ,  $I_H$ ,  $t_H$ ,  $t_{SW}$ , (and  $V_H$  where appropriate). Measurement delay time ( $t_{MD}$ ) = 70  $\mu$ s max. See table III, group E, subgroup 4 herein.
  - 4.4 Conformance inspection. Conformance inspection shall be in accordance with MIL-PRF-19500.
- 4.4.1 <u>Group A inspection</u>. Group A inspection shall be conducted in accordance with MIL-PRF-19500 and table I herein. Electrical measurements (end-points) shall be in accordance with the inspections of table I herein.
- 4.4.2 <u>Group B inspection</u>. Group B inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-VIA (JANS) and table E-VIB (JAN, JANTX, and JANTXV) of MIL-PRF-19500, and herein. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.
  - 4.4.2.1 Group B inspection, table E-VIA (JANS) of MIL-PRF-19500.

Subgroup	Method	Condition
В3	1051	Test condition G, 100 cycles.
B5	1042	Accelerated steady-state gate bias, condition B, $V_{GS}$ = rated $V_{GS}$ ; $T_A$ = +175°C, $t$ = 24 hours minimum; or $T_A$ = +150°C, $t$ = 48 hours minimum.
B5	1042	Accelerated steady-state reverse bias, condition A, $V_{DS}$ = rated $V_{DS}$ ; $T_A$ = +175°C, t = 120 hours minimum; or $T_A$ = +150°C, t = 240 hours minimum.
B5	2037	Test condition D.

### 4.4.2.2 Group B inspection, table E-VIB (JANTXV) of MIL-PRF-19500.

<u>Subgroup</u>	<u>Method</u>	Condition
B2	1051	Test condition C, 25 cycles.
В3	1042	Accelerated steady-state gate bias, condition B, $V_{GS}$ = rated $V_{GS}$ ; $T_A$ = +175°C, t = 24 hours minimum; or $T_A$ = +150°C, t = 48 hours minimum; and accelerated steady-state reverse bias, condition A, $V_{DS}$ = rated $V_{DS}$ ; $T_A$ = +175°C, t = 170 hours minimum; or $T_A$ = +150°C, t = 340 hours minimum.

4.4.3 <u>Group C inspection</u>. Group C inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-VII of MIL-PRF-19500 and as follows. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.

<u>Subgroup</u>	Method	Condition
C2	2036	Test condition E.
C5	3161	See 4.5.2, $R_{\theta JC}$ = (see 1.3).
C6	1042	Accelerated steady-state gate bias, condition B, $V_{GS}$ = rated $V_{GS}$ ; $T_A$ = +175°C, $t$ = 48 hours minimum; or $T_A$ = +150°C, $t$ = 96 hours minimum. and accelerated steady-state reverse bias, condition A, $V_{DS}$ = rated $V_{DS}$ ; $T_A$ = +175°C, $t$ = 500 hours minimum; or $T_A$ = +150°C, $t$ = 1,000 hours minimum.

- 4.4.4 <u>Group D inspection</u>. Group D inspection shall be conducted in accordance with table E-VIII of MIL-PRF-19500 and table II herein.
- 4.4.5 <u>Group E inspection</u>. Group E inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-IX of MIL-PRF-19500 and as specified in table II herein. Electrical measurements (endpoints) shall be in accordance with table I, subgroup 2 herein.
- 4.5 <u>Methods of inspection</u>. Methods of inspection shall be as specified in the appropriate tables and as follows.
- 4.5.1 Pulse measurements. Conditions for pulse measurement shall be as specified in section 4 of MIL-STD-750.
- 4.5.2 <u>Thermal resistance</u>. The thermal resistance measurements shall be performed in accordance with method 3161 of MIL-STD-750 using the guidelines in that method for determining  $I_M$ ,  $I_H$ , I

TABLE I. Group A inspection.

Inspection 1/		MIL-STD-750	Symbol		nits	Unit
	Method	Condition		Min	Max	
Subgroup 1						
Visual and mechanical inspection	2071					
Subgroup 2						
Thermal impedance 2/	3161	See 4.3.3	Z <sub>θJC</sub>			°C/W
Breakdown voltage drain to source	3407	$V_{GS} = 0$ , $I_D = 250~\mu A$ dc, bias condition C	$V_{(BR)DSS}$	100		V dc
Gate to source voltage (threshold)	3403	$V_{DS} \geq V_{GS}, \ I_D = 250 \ \mu A \ dc$	$V_{GS(TH)1}$	1.0	2.0	V dc
Gate current	3411	$V_{GS} = +10 \text{ V dc}$ , bias condition C, $V_{DS} = 0$	I <sub>GSSF1</sub>		+100	nA dc
Gate current	3411	$V_{GS} = -10 \text{ V dc}$ , bias condition C, $V_{DS} = 0$	I <sub>GSSR1</sub>		-100	nA dc
Drain current	3413	$V_{GS}$ = 0, bias condition C, $V_{DS}$ = 80 percent of rated $V_{DS}$	I <sub>DSS1</sub>		1.0	μA dc
Static drain to source on-state resistance	3421	$V_{GS}$ = 4.5 V dc, condition A, pulsed (see 4.5.1), $I_D = I_{D2}$	r <sub>DS(ON)1</sub>		0.30	Ω
Forward voltage	4011	$V_{GS}$ = 0, condition A, pulsed (see 4.5.1), $I_D = I_{D1}$	V <sub>SD</sub>		1.2	V (pk)
Subgroup 3						
High temperature operation:		$T_{C} = T_{J} = +125^{\circ}C$				
Gate current	3411	$V_{GS} = \pm 10 \text{ V dc}$ , bias condition C, $V_{DS} = 0$	$I_{GSS2}$		±200	nA dc
Drain current	3413	$V_{GS}$ = 0, bias condition C, $V_{DS}$ = 80 percent of rated $V_{DS}$	I <sub>DSS2</sub>		10	μA dc
Static drain to source on-state resistance	3421	$V_{GS}$ = 4.5 V dc, condition A, pulsed (see 4.5.1), $I_D$ = $I_{D2}$	r <sub>DS(ON)2</sub>		0.60	Ω
Gate to source voltage (threshold)	3403	$V_{DS} = V_{GS}, I_D = 250 \mu A dc$	$V_{\text{GS(TH)2}}$	0.5		V dc
Low temperature operation:		$T_C = T_J = -55$ °C				
Gate to source voltage (threshold)	3403	$V_{DS} \ge V_{GS}, I_D = 250 \ \mu A \ dc$	$V_{\text{GS(TH)}3}$		2.5	V dc

See footnotes at end of table.

TABLE I. Group A inspection - Continued.

Inspection 1/		MIL-STD-750	Symbol	Lim	its	Unit
	Method	Condition		Min	Max	
Subgroup 4						
Forward transconductance	3475	$V_{DS} = 10 \text{ V dc}, I_{D} = I_{D2}, \text{ pulsed (see 4.5.1)}$	<b>g</b> FS	3.0		S
Gate series resistance	3402	Condition A	R <sub>G</sub>		14	Ω
Electrical measurements		See table I, subgroup 2				
Subgroup 5						
Safe operating area test	3474	$V_{DS}$ = 80 percent of rated $V_{DS}$ (see 1.3) $t_P$ = 10 ms, $I_D$ as specified in figure 4				
Electrical measurements		See table I, subgroup 2				
Subgroups 6						
Not applicable						
Subgroup 7						
Gate charge	3471	Condition B, $I_D = I_{D1}$ , $V_{DD} = 50$ percent rated				
On-state gate charge and turn-off gate charge		$V_{DS}$	$\begin{array}{c}Q_{G(ON)}\\Q_{G(OFF)}\end{array}$		9.0	nC
Gate to source charge (turn-on and turn-off)			$\begin{array}{c} Q_{GS1} \\ Q_{GS2} \end{array}$		3.2	nC
Gate to drain charge (turn-on and turn-off)			$\begin{array}{c}Q_{GD1}\\Q_{GD2}\end{array}$		4.8	nC
Reverse recovery time	3473	$di/dt = -100 \text{ A/}\mu\text{s}, V_{DD} \le 25 \text{ V}, I_D = I_{D1}$	t <sub>rr</sub>		260	ns
Subgroup 7						
Not applicable						

For sampling plan, see MIL-PRF-19500.
This test required for the following end-point measurements only:
Group B, subgroups 3 and 4 (JANS).
Group B, subgroups 2 and 3 (JANTXV).
Group C, subgroup 2 and 6.
Group E, subgroup 1.

# TABLE II. Group D inspection.

Inspection <u>1</u> / <u>2</u> / <u>3</u> /	MIL-STD-750		Symbol	Pre-irradiation limits		Post- irradiation limits		irrad lin	ost- liation nits	Unit
	Method	Conditions		R a Min	nd F Max	Min	R Max	Min	F Max	
Subgroup 1										
Not applicable										
Subgroup 2		T <sub>C</sub> = + 25°C								
Steady-state total dose irradiation (V <sub>GS</sub> bias) <u>4</u> /	1019	$V_{GS} = 6 \text{ V};$ $V_{DS} = 0$								
Steady-state total dose irradiation (V <sub>DS</sub> bias) <u>4</u> /	1019	$V_{GS} = 0;$ $V_{DS} = 80$ percent of rated $V_{DS}$ (preirradiation)								
End-point electricals:										
Breakdown voltage, drain to source	3407	$V_{GS}$ = 0; $I_D$ = 250 $\mu A$ ; bias condition C	V <sub>(BR)DSS</sub>	100		100		100		V dc
Gate to source voltage (threshold)	3403	$V_{DS} \ge V_{GS}$ $I_D = 250 \mu A$	V <sub>GS(th)1</sub>	1.0	2.0	1.0	2.0	1.0	2.0	V dc
Gate current	3411	$V_{GS} = +10 \text{ V}, V_{DS} = 0,$ bias condition C	I <sub>GSSF1</sub>		100		100		100	nA dc
Gate current	3411	$V_{GS} = -10 \text{ V}, V_{DS} = 0,$ bias condition C	I <sub>GSSR1</sub>		-100		-100		-100	nA dc
Drain current	3413	$V_{GS}$ = 0, bias condition C $V_{DS}$ = 80 percent of rated $V_{DS}$ (preirradiation)	I <sub>DSS</sub>		1.0		1.0		1.0	μA dc
Static drain to source on-state voltage	3405	$V_{GS}$ = 4.5 V; condition A, pulsed (see 4.5.1), $I_{D1}$ = $I_{D2}$	V <sub>DS(on)</sub>		1.110		1.110		1.110	V dc
Forward voltage source drain diode	4011	$V_{GS} = 0$ ; $I_D = I_{D1}$ bias condition C	V <sub>SD</sub>		1.2		1.2		1.2	V dc

 <sup>1/</sup> For sampling plan see MIL-PRF-19500.
 2/ Group D qualification may be performed prior to lot formation. Wafers qualified to these group D QCI requirements may be used for any other specification sheets utilizing the same die design.

<sup>3/</sup> At the manufacturer's option, group D samples need not be subjected to the screening tests, and may be assembled in its qualified package or in any qualified package that the manufacturer has data to correlate the performance to the designated package.

<sup>4/</sup> Separate samples shall be pulled for each bias.

TABLE III. Group E inspection (all quality levels) - for qualification or re-qualification only.

Inspection		MIL-STD-750		
	Method	Conditions	plan	
Subgroup 1			45 devices c = 0	
Temperature cycling	1051	Condition G, 500 cycles	C = 0	
Hermetic seal Fine leak Gross leak	1071	As applicable		
Electrical measurements		See table I, subgroup 2		
Subgroup 2 1/			45 devices	
Steady-state gate bias	1042	Condition B, 1,000 hours	c = 0	
Electrical measurements		See table I, subgroup 2		
Steady-state reverse bias	1042	Condition A, 1,000 hours		
Electrical measurements		See table I, subgroup 2		
Subgroup 3			n = 45,	
Switching time test	3472	$\begin{split} & I_D = I_{D1},  V_{GS} = 5.0  \text{V dc},  R_G = 7.5  \Omega, \\ & V_{DD} = 50  \text{percent rated}  V_{DS} \\ & \text{Typical measurements:}  t_{d(on)} = 15  \text{ns};  t_r = 85  \text{ns}; \\ & t_{d(off)} = 35  \text{ns};  t_f = 10  \text{ns} \end{split}$	c = 0	
Subgroup 4			Sample	
Thermal impedance curves	3161	See MIL-PRF-19500	size N/A	
Subgroup 10			22 devices	
Commutating diode for safe operating area test procedure for measuring dv/dt during reverse recovery of power MOSFET transistors or insulated gate bipolar transistors	3476	Test conditions shall be derived by the manufacturer	c = 0	

TABLE III. Group E inspection (all quality levels) for qualification or re-qualification only - Continued.

	1							
		Sample plan						
Inspection	Method	Method Conditions						
Subgroup 11			3 devices					
SEE <u>2</u> / <u>3</u> / <u>4</u> /	1080	See figure 5						
Electrical measurements 5/		$I_{\text{GSSF1}}$ , $I_{\text{GSSR1}}$ , and $I_{\text{DSS1}}$ in accordance with table I, subgroup 2						
SEE irradiation		Fluence = 3E5 ±20 percent ions/cm² Flux = 2E3 to 2E4 ions/cm²/sec, temperature = 25° ±5 °C Surface LET = 38 MeV-cm²/mg ±5%, range = 38 $\mu$ m ±7.5%, energy = 300 MeV ±7.5% In situ bias conditions: V <sub>DS</sub> = 100 V and V <sub>GS</sub> = -7 V (typical 3.77 MeV/nucleon at Texas A & M Cyclotron) Surface LET = 62 MeV-cm²/mg ±5%, range = 33 $\mu$ m ±7.5%, energy = 355 MeV ±7.5% In situ bias conditions: V <sub>DS</sub> = 100 V and V <sub>GS</sub> = -6 V (typical 2.88 MeV/nucleon at Texas A & M Cyclotron) Surface LET = 85 MeV-cm²/mg ±5%, range = 29 $\mu$ m ±7.5%, energy = 380 MeV ±10% In situ bias conditions: V <sub>DS</sub> = 100 V and V <sub>GS</sub> = -5 V (typical 2.05 MeV/nucleon at Texas A & M Cyclotron)						
Electrical measurements 5/		I <sub>GSSF1</sub> , I <sub>GSSR1</sub> , and I <sub>DSS1</sub> in accordance with table I, subgroup 2						

- 1/ A separate sample for each test shall be pulled.
   2/ Group E qualification of SEE effect testing may be performed prior to lot formation. Qualification may be extended to other specification sheets utilizing the same structurally identical die design.
- 3/ Device qualification to a higher level LET is sufficient to qualify all lower level LETs.
- 4/ The sampling plan applies to each bias condition.
  5/ Examine IgssF1, IgssR1, and IDss1 before and following SEE irradiation to determine acceptability for each bias condition. Other test conditions in accordance with table I, subgroup 2, may be performed at the manufacturer's option.

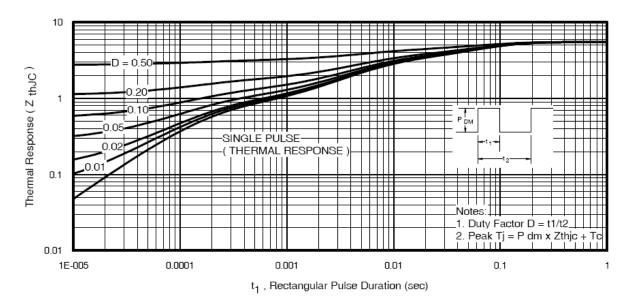


FIGURE 2. Thermal impedance graph.

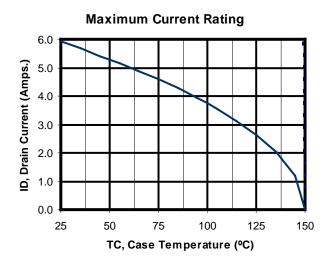


FIGURE 3. Derating drain current.

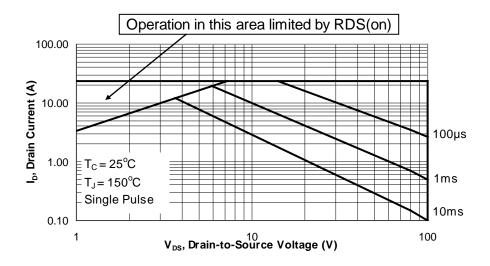


FIGURE 4. Safe operating area graph.

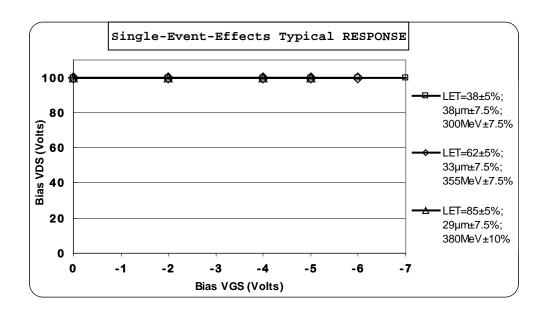


FIGURE 5. Typical single event effects safe operating area graph.

#### 5. PACKAGING

5.1 <u>Packaging</u>. For acquisition purposes, the packaging requirements shall be as specified in the contract or order (see 6.2). When packaging of materiel is to be performed by DoD or in-house contractor personnel, these personnel need to contact the responsible packaging activity to ascertain packaging requirements. Packaging requirements are maintained by the Inventory Control Point's packaging activities within the Military Service or Defense Agency, or within the Military Service's system commands. Packaging data retrieval is available from the managing Military Department's or Defense Agency's automated packaging files, CD-ROM products, or by contacting the responsible packaging activity.

#### 6. NOTES

(This section contains information of a general or explanatory nature that may be helpful, but is not mandatory. The notes specified in MIL-PRF-19500 are applicable to this specification.)

- 6.1 <u>Intended use</u>. Semiconductors conforming to this specification are intended for original equipment design applications and logistic support of existing equipment.
  - 6.2 <u>Acquisition requirements</u>. Acquisition documents should specify the following:
  - a. Title, number, and date of this specification.
  - b. Packaging requirements (see 5.1).
  - c. Lead finish (see 3.4.1).
  - d. Product assurance level and type designator.
- 6.3 Qualification. With respect to products requiring qualification, awards will be made only for products which are, at the time of award of contract, qualified for inclusion in Qualified Manufacturers List (QML 19500) whether or not such products have actually been so listed by that date. The attention of the contractors is called to these requirements, and manufacturers are urged to arrange to have the products that they propose to offer to the Federal Government tested for qualification in order that they may be eligible to be awarded contracts or orders for the products covered by this specification. Information pertaining to qualification of products may be obtained from Defense Supply Center, Columbus, ATTN: DSCC/VQE, P.O. Box 3990, Columbus, OH 43218-3990 or e-mail <a href="mailto:vqe.chief@dla.mil">vqe.chief@dla.mil</a>. An online listing of products qualified to this specification may be found in the Qualified Products Database (QPD) at <a href="https://assist.daps.dla.mil">https://assist.daps.dla.mil</a>.
- 6.4 <u>Cross-reference list</u>. The following table shows the generic P/N and its associated military P/N (without JAN and RHA prefix).

Generic P/N	Military P/N
IRHLF77110	2N7608T2

Custodians:

Army - CR Navy - EC Air Force - 85 NASA - NA DLA - CC Preparing activity: DLA - CC

(Project 5961-2010-073)

NOTE: The activities listed above were interested in this document as of the date of this document. Since organizations and responsibilities can change, you should verify the currency of the information above using the ASSIST Online database at <a href="https://assist.daps.dla.mil">https://assist.daps.dla.mil</a>.